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Information Disclosure Statement by Applicant (Use several sheets if necessary)		APPLICANT Kitson	
		FILING DATE January 10, 2002	GROUP 2854



## U.S. PATENT DOCUMENTS

Exmr Initial	Document Number	Date	Name	Class	Sub Class	Filing Date
g	4,532,005	7/1985	Grieco et al.	216	47	
	4,708,925	11/1987	Newman	430	270	
	5,563,011	10/1996	Shipley	430	7	
	5,609,995	3/1997	Akram et al.	430	327	
	6,294,311 B1	9/2001	Shimazu et al.	430	271.1	
	6,352,811 B1	3/2002	Patel et al.	430	270.1	
	6,352,812 B1	3/2002	Shimazu et al.	430	273.1	
↓	6,358,669 B1	3/2002	Savarjar-Hauck et al.	430	273.1	

## FOREIGN PATENT DOCUMENTS

Exmr Initial	Document Number	Date	Country	Class	Sub Class	Translation YES   NO
g	0 708 372 A1	4/1996	EP			
	0 823 327 A2	2/1998	EP			
	0 864 420 A1	9/1998	EP			
	0 908 305 A1	4/1999	EP			
	0 908 307 A2	4/1999	EP			
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	2001042509	2/2001	JP (English Abstract provided)			
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## OTHER DOCUMENTS

(Including Author, Title, Date, Pertinent Pages, Etc.)

		"Diazonaphthoquinone-based Resists," R. Dammel, pp. 104-106, SPIE, 1993
		"Positive Resists Based on Diazonaphthoquinones," in <i>Photoreactive Polymers</i> , A. Reiser, pp. 179-225, Wiley, 1989

Examiner	J. Chin	Date Considered	9/2004
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Examiner: Initial if citation considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.